

## **Abstract of Disclosure**

The present invention discloses a reformed wafer boat. The  
5 reformed wafer boat has a plurality of trenches. A first interval is  
formed between each trench and one adjacent trench, and a second  
interval is formed between each trench and the other adjacent  
trench. The wafers placed on the trenches at both ends of the  
second interval are in form of back to back, and the first interval is  
10 formed between surfaces of each wafers. This kind of design does  
not affect uniformity during process, and the throughput can also  
be effectively improved.